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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/764,520	01/27/2004	Tokihiro Nishihara	020494A	9968
23850 7.	590 07/12/2006		EXAMINER	
ARMSTRON	G, KRATZ, QUINTO	ESTRADA, MICHELLE		
1725 K STREE	ET, NW			
SUITE 1000			ART UNIT	PAPER NUMBER
WASHINGTO	N, DC 20006		2823	

DATE MAILED: 07/12/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
0.00		10/764,520	NISHIHARA ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Michelle Estrada	2823			
Period fo	The MAILING DATE of this communication apor Reply	opears on the cover sheet with the c	orrespondence address			
WHI(- Exte after - If NO - Failu Any	ORTENED STATUTORY PERIOD FOR REP CHEVER IS LONGER, FROM THE MAILING I nsions of time may be available under the provisions of 37 CFR 1 SIX (6) MONTHS from the mailing date of this communication. O period for reply is specified above, the maximum statutory period are to reply within the set or extended period for reply will, by status reply received by the Office later than three months after the mailined patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION .136(a). In no event, however, may a reply be tind d will apply and will expire SIX (6) MONTHS from the, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)[🛛	Responsive to communication(s) filed on 24	April 2006.				
′=		is action is non-final.				
3)□	, ==					
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposit	ion of Claims					
4)⊠	Claim(s) 28-31 is/are pending in the applicati	on.				
•	4a) Of the above claim(s) is/are withdrawn from consideration.					
5)[5) Claim(s) is/are allowed.					
6)⊠	☐ Claim(s) <u>28-31</u> is/are rejected.					
7)						
8)[Claim(s) are subject to restriction and	or election requirement.				
Applicat	ion Papers					
9)⊠	The specification is objected to by the Examir	ner.				
10)	The drawing(s) filed on is/are: a) ac	ccepted or b) objected to by the I	Examiner.			
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
	Replacement drawing sheet(s) including the corre	ction is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).			
11)	The oath or declaration is objected to by the E	Examiner. Note the attached Office	Action or form PTO-152.			
Priority (under 35 U.S.C. § 119					
	Acknowledgment is made of a claim for foreig ☐ All b)☐ Some * c)☐ None of:	n priority under 35 U.S.C. § 119(a))-(d) or (f).			
	1. Certified copies of the priority documents have been received.					
	2. Certified copies of the priority documents have been received in Application No					
	3. Copies of the certified copies of the priority documents have been received in this National Stage					
application from the International Bureau (PCT Rule 17.2(a)).						
~ `	See the attached detailed Office action for a lis	st of the certified copies not receive	; G .			
Attachmen	t(s)					
_	e of References Cited (PTO-892)	4) Interview Summary	(PTO-413)			
2) 🔲 Notic	e of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	ate			
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 6/13/06. 5) Notice of Informal Patent Application (PTO-152) 6) Other:						

DETAILED ACTION

Specification

The disclosure is objected to because of the following informalities: in the preliminary amendment to the specification filed 1/27/04, it appears that an update to the status of application 10/117,216 is needed.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 28, 30 and 31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wadaka et al. (5,789,845) in view of Sumi (6,402,303).

Re claim 31, Wadaka et al. Lin et al. disclose preparing a substrate (1) including a first surface and a second surface opposite to said first surface; forming a resonator assembly which includes a first electrode (5) held in contact with said first surface, a piezoelectric layer (2) formed on the first electrode and a second electrode (6) formed on the piezoelectric layer; and forming a cavity on the substrate, the cavity being disposed at a location corresponding to the resonator assembly, the cavity being opened in said first surface and said second surface (See fig. 74); wherein the first

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electrode and the piezoelectric layer are partially and directly exposed to the cavity at the cavity-forming step (See fig. 74).

Wadaka et al. do not specifically disclose forming the cavity by dry etching the substrate.

Sumi discloses dry etching a cavity on a substrate (20), which has a piezoelectric formed therein (Col. 10, lines 1-5).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Wadaka et al. and Sumi to enable the cavity formation step of Wadaka et al. to be performed according to the teachings of Sumi because one of ordinary skill in the art would have been motivated to look to alternative suitable methods of performing the disclosed cavity formation step of Wadaka et al. and art recognized suitability for an intended purpose has been recognized to be motivation to combine. See MPEP 2144.07.

Re claim 28, Sumi disclose wherein the dry etching is deep-RIE.

Re claim 30, Sumi discloses wherein a groove for dividing the substrate is also formed by etching at the cavity-forming step.

Claim 29 is rejected under 35 U.S.C. 103(a) as being unpatentable over Wadaka et al. in view of Sumi as applied to claims 28, 30 and 31 above, and further in view of Hasegawa et al. (2002/0011986).

The combination does not disclose further comprising the step of bonding a cover substrate to said second surface so as to close the cavity.

Hasegawa et al. disclose further comprising the step of bonding a cover substrate (506) to said second surface so as to close the cavity (See fig. 9 and page 5, [0069].

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Wadaka et al., Sumi and Hasegawa et al. to enable the cover substrate formation step of Hasegawa et al. to be performed in the process of the combination to allow the piezoelectric to vibrate and supply a voltage amplified alternating signal to the lower electrode.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Estrada whose telephone number is 571-272-1858. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 571-272-2800.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Michellé Estrada Primary Examiner Art Unit 2823 Page 5